



Correction: A single-source precursor route to anisotropic halogen-doped zinc oxide particles as a promising candidate for new transparent conducting oxide materials

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Correction

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In the original article an incorrect graphic was displayed for Figure 8. The correct form of Figure 8 is as follows:

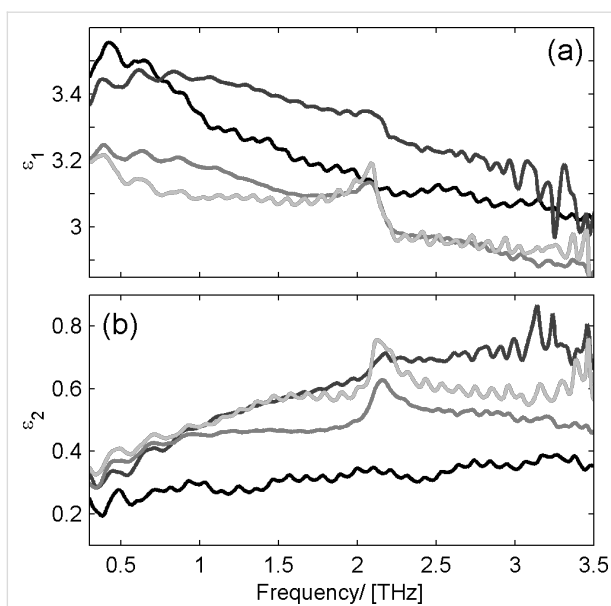


Figure 1: Figure 8 in the original article: Measured dielectric function of $\text{ZnO}_{1-x}\text{Cl}_x$ (a) real part; (b) imaginary part with $x = 0.0\%$ (black lines), 1.4% (dark gray lines), 1.8% (gray lines) and 2.5% (light gray lines); An infrared-active phonon at about 2 THz is scaling in intensity with increasing Cl concentration.

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